

# CERTIFICATE

Certificate No. 2025-014
This is to certify that the products listed below produced by

#### SANITAR CO., LTD.

are in compliance with the requirements of nanoMark Product Certification System

I. Company Name: SANITAR CO., LTD.

II. Company Certificate: No.028

III. Address: 7F, NO. 111-8, HSING DE ROAD, SAN CHUNG CITY,

**TAIPEI, TAIWAN.** (Application)

NHONTRACH I INDUSTRIAL ZONE, DONG NAI PROVINCE,

**VIETNAM**(Factory)

IV. Representative: HSIAO, CHUN-HSIANG

V. Approved product : Anti-Smudge Sanitary Facilities

VI. Product name, model/specification, approved item number and efficacy: please refer to the Appendix

VII. Date of Certificate Issuance: Jul. 01, 2025

Date of Certificate Expiration: Jun. 30, 2026





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I. Company Name: SANITAR CO., LTD.

II. Approved product: Anti-Smudge Sanitary Facilities

III. Product name, model/specification, approved item number and efficacy:

Product name	Model	Approved item number	Efficacy
	C1358	01919	
	C1458	01920	In compliance with
	CF1347	01925	the requirements
	CF1447	01926	of 「TN-008 Standard on Anti-
	CA1380	01935	Smudgy Sanitary
	CF1475	01938	Facilities : the
	CPT1503	01941	following
	CPT1502	01942	specifications are satisfied.
	CPT1501	01943	(1)The water
	CF1356	01944	contact angle is
	CF1456	01945	higher than
	CA1390	01946	100°. The residual ratio of
	C1352	01947	contaminant is
	C1379	01948	less than 1%.
One piece	C1479	01949	The residual ratio of dense-
toilet	CA1381	01950	contaminant is
	CF1378	01952	less than 1%.
	CF1478	01953	(2)Durability (scrul
	C1353	02816	resistance) test : The
	C1453	02817	contact angle is
	CF1382	02820	higher than 100
	CP1504	02821	after 2000
	CP1506	02822	cycles of scrubbing, the
	CF1344	02823	residual ratio of
	CF1444	02824	contaminant is
	C1364	02825	less than 1% and the residual
ļ	C1464	02826	ratio of dense
	CF1342	02827	contaminant is
	CF1442	02828	less than 5%.
	C1680	02829	

Product name	Model	Approved item number	Efficacy
	C1385	02830	
	C1650	02831	In compliance with
	C1383	03045	the requirements
	C1384	03046	of 「TN-008 Standard on Anti-
	C1561	03047	Smudgy Sanitary
	CF1394	03145	Facilities」: the
	CF1375-PW	03146	following
	CF1374-PW	03147	specifications are satisfied,
	CF1474-PW	03148	(1)The water
One piece	C13170	03218	contact angle is
One piece	C14170	03219	higher than 100°. The
tolict	CF1494	03220	residual ratio of
	C1386	03221	contaminant is
	CF1354	03222	less than 1%.
	CF1454	03223	The residual ratio of dense-
	CF1395	03519	contaminant is
	CPT1505	03582	less than 1%.
	CA1380S	03949	(2)Durability (scrub
	CF1391	03950	tests : The
	CA1392	03951	contact angle is
	CF1393	03952	higher than 100°
	CF1240	01955	after 2000 cycles of
	CF1340	01956	scrubbing, the
	CF1345	701960	residual ratio of
Close-couple	CF1346	Q1 <mark>961</mark>	contaminant is less than 1%
toilet	CF1446	01962	and the residual
	CT1323	01963	ratio of dense
	CT1325	01964	contaminant is less than 5%.
	CT1425	01965	1555 HIGH 570.
	CF1325	01966	

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	CF1425	01967	
	CT1326	01968	In compliance with
	CT1426	01969	the requirements
	CB1326	01970	of 「TN-008 Standard on Anti-
	CB1426	01971	Smudgy Sanitary
	CF1330	01972	Facilities : the
	CF1331	01973	following
	CF1431	01974	specifications are satisfied.
	CF1338	01975	(1)The water
	CPT1332	01976	contact angle is
	CP1333	01977	higher than
	CF1440	01978	100°. The residual ratio of
	CT1026	01980	contaminant is
	CF1348	01984	less than 1%.
Close-couple	CF1448	01985	The residual ratio of dense-
toilet	CF1341	01986	contaminant is
	CF1441	01987	less than 1%.
	CF1349	01988	(2)Durability (scrub
	CF1449	01989	resistance) test:The
	CT1325J	01990	contact angle is
	CT1425J	01991	higher than 100°
	CF1325J	01992	after 2000
	CF1425J	01993	cycles of scrubbing, the
	CF1151	01994	residual ratio of
	CF1351	01996	contaminant is
	CF1530U	02832	less than 1% and the residual
	CF1530N	02833	ratio of dense
	CF1551U	02834	contaminant is
	CF1551N	02835	less than 5%.
	CF1551P	02836	

Product name	Model	Approved item number	Efficacy
	CF1545U	02837	
	CF1545N	02838	In compliance with
	CF1545P	02839	the requirements
	C1649	02840	of 「TN-008 Standard on Anti-
	CJU1550	02841	Smudgy Sanitary
	CJN1550	02842	Facilities」: the
	CJP1550	02843	following
	CJP1550A	02844	specifications are satisfied,
	CJP1550B	02845	(1)The water
	CJN1550A	02846	contact angle is
	CJN1550B	02847	higher than 100°. The
	CJU1550A	02848	residual ratio of
	CJU1550B	02849	contaminant is
	CT1423	02850	less than 1%.
Close-couple	CF1320-PW	03149	The residual ratio of dense-
toilet	CF1320-BI	03150	contaminant is
	CF1420-PW	03151	less than 1%.
	CF1420-BI	03152	(2)Durability (scrub
	CTH1325	03520	resistance) test: The
	CTH1425	03521	contact angle is
	CF1540	03522	higher than 100°
	CB1325	03583	after 2000 cycles of
	CB1425	03584	scrubbing, the
	CF1363	03585	residual ratio of
	C1026	03 <mark>586</mark>	contaminant is
	CTA1325	03887	less than 1% and the residual
	CTA1425	03888	ratio of dense
	CPJ1334	03953	contaminant is
	CT1342	03954	less than 5%.
	CPT1506	03955	,11111

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III. Product name, model/specification, approved item number and efficacy:

Product name	Model	Approved item number	Efficacy
	C1230	01998	
	CS1230	01999	In compliance with
	C1250	02000	the requirements
	CT1250	02001	of 「TN-008 Standard on Anti-
Squatting toilet	C1280	02003	Smudgy Sanitary
	CS1280	02004	Facilities : the
	C1290	02005	following
	C1230B	03523	specifications are satisfied.
	C1250B	03524	(1)The water
	L2155	02006	contact angle is
	L2230	02007	higher than
	L2360S	02011	100°. The residual ratio of
	L2560	02012	contaminant is less than 1%.
	L5121	02015	
	LF5024	02019	The residual ratio of dense-
	LF5026	02020	contaminant is less than 1%. (2)Durability (scrub
	LF5028	02021	
	LF5030	02022	
	LF5032	02023	resistance) test : The
Wash Basin	L5119	02024	contact angle is
	LF5236	02029	higher than 100°
	LF5240	02030	after 2000
	LF5302	02033	cycles of scrubbing, the
	LF5304	02034	residual ratio of
	LF5306	02035	contaminant is
	LF5312	02038	less than 1% and the residual
	LF5314	02039	ratio of dense
<sub> </sub>	LF5316	02040	contaminant is
	LF5318	02041	less than 5%.
, İ	LF5320	02042	

Product name	Model	Approved item number	Efficacy
	LF5338	02044	
	L2220	02045	In compliance with
	L2150	02046	the requirements
	L5018	02049	of 「TN-008 Standard on Anti-
	L5020	02050	Smudgy Sanitary
	L5113	02052	Facilities」: the
	L5115	02053	following
	L5222	02055	specifications are satisfied,
	LF5232	02056	(1)The water
	LF5238	02057	contact angle is
	L2014	02058	higher than 100°. The
	L5215	02059	residual ratio of
	LF5252	02061	contaminant is
	LF5254	02062	less than 1%.
Wash Basin	LF5256	02063	The residual ratio of dense-
Wasii Dasiii	LF5258	02064	contaminant is
	LF5239R	02066	less than 1%.
	LF5239S	02067	(2)Durability (scrub
	LF5324	02068	resistance) test: The
	LF5036	02069	contact angle is
	LF2270	02070	higher than 100°
	LF2015A -	02071	after 2000
	L5125	02072	scrubbing, the
	LF5016	02851	residual ratio of
	LF5017	02 <mark>852</mark>	contaminant is less than 1%
	LF5118	02853	and the residual
	LF5128	02854	ratio of dense
	LF5130	02855	contaminant is less than 5%.
	LF5038	02863	less than 5%.
	LF5253	02864	

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Product name	Model	Approved item number	Efficacy
	LF5120	02865	
	LF5255	02867	In compliance with
	LF5257	02868	the requirements
	LF5019	02869	of 「TN-008 Standard on Anti-
	LF5380	02870	Smudgy Sanitary
	LF5382	02871	Facilities : the
	LF5384	02872	following
	LF5386	02873	specifications are satisfied.
	LF5388	02874	(1)The water
	LF5260	02875	contact angle is
	LF5364	02876	higher than
	LF5362	02877	100°. The residual ratio of
	LF5368	02878	contaminant is less than 1%. The residual ratio of densecontaminant is less than 1%.
	LF5370	02879	
Mark Darie	LF5372	02880	
Wash Basin	LF5374	02881	
	LF5376	02882	
	LF5019S	02883	(2)Durability (scrub
	LF2270S	02884	resistance) test:The
	L2560S	02885	contact angle is
	L2230S	02886	higher than 100
	L2220S	02887	after 2000
	L2220D	02888	cycles of scrubbing, the
	L2155S	02889	residual ratio of
	L2155D	02890	contaminant is
	L2150S	02891	less than 1% and the residual
	L2150D	02892	ratio of dense
	L2150H	02893	contaminant is
	L2150DH	02894	less than 5%.
	L2140S	02895	

Product name	Model	Approved item number	Efficacy
	L2140D	02896	
	L2140H	02897	In compliance with
	L5018S	02898	the requirements
	L5018D	02899	of 「TN-008 Standard on Anti-
	LF5126	02900	Smudgy Sanitary
	LF5259	03048	Facilities」: the
	L2152S	03117	following
	L2152D	03118	specifications are satisfied,
	L2152H	03119	(1)The water
	L2152DH	03120	contact angle is
	L2365S	03121	higher than 100°. The
	L5261	03122	residual ratio of
	L5216	03123	contaminant is
	LF5239L	03153	less than 1%. The residual
Wash Basin	L5019	03154	ratio of dense-
Wash Bash	LF5040	03155	contaminant is
	LF5261	03156	less than 1%.
	L5221	03224	(2)Durability (scrub
	LF5127	03225	test: The
	LF5240	03525	contact angle is
	LF5263	03526	higher than 100°
	L5019	03587	after 2000 cycles of
	LF5025S	03889	scrubbing, the
	LF5027S	03890	residual ratio of
	LF5301S	03 <mark>891</mark>	contaminant is less than 1%
	LF5356S	03956	and the residual
	LF5357S	03957	ratio of dense
	LF53588	03958	contaminant is less than 5%.
	LF5359S	03959	1055 111211 376.
	L5262	03960	

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Product name	Model	Approved item number	Efficacy
Wash Basin	L5225	03961	
	U0210	02077	In compliance with
	U0261	02080	the requirements of FTN-008
	U0262	02081	Standard on Anti-
	U0291	02083	Smudgy Sanitary
	UA0295	02086	Facilities : the
	UA0283	02087	following
	U0282	02088	specifications are satisfied.
	U0296	02089	(1)The water
	U0231	02090	contact angle is
	U0240	02093	higher than 100°. The
	U0285	02094	residual ratio of
	U0221	02095	contaminant is
	UA0287	02096	less than 1%.
	UF0265	02097	The residual ratio of dense-
Urinal	UF0286	02098	contaminant is
	U0230	02099	less than 1%.
	UMP0287	02100	(2)Durability (scrub resistance)
	UMP0283	02101	test: The
	UMP0295	02102	contact angle is
	U0284	02901	higher than 100°
	U0288	02902	after 2000 cycles of
	U0264	02903	scrubbing, the
	U0266	02904	residual ratio of
	U0252	02905	contaminant is less than 1%
	U0267	02906	and the residual
	U0232	03049	ratio of dense
	U0233	03050	contaminant is less than 5%.
	U0289	03051	1655 (11411 576.
	U0237	03124	

Product name	Model	Approved item number	Efficacy
	U0239	03125	
	U0211	03157	In compliance with
	UA0234	03226	the requirements
	UA0237	03227	of 「TN-008 Standard on Anti-
	U0234	03238	Smudgy Sanitary
l lain a l	U0235	03239	Facilities : the
Urinal	UMP0284	03240	following
	U0297S	03962	specifications are satisfied.
	U0297	03963	(1)The water
	U0298S	03964	contact angle is
	U0298	03965	higher than
	U0298C	03966	100°. The residual ratio of
			The residual ratio of dense-contaminant is less than 1%.  (2)Durability (scrub resistance)
	1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1		test: The contact angle is
			higher than 100 after 2000 cycles of scrubbing the residual ratio of comments and the residual ratio of dense con aminant is less than 1% less than 5%.

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